IN THE CLAIMS

Please cancel claims 29 and 31 without prejudice.

Please amend the following claims which are pending in the present

application:

1-27. (Cancelled)

28. (Currently amended) A method of making a plurality of dice, comprising:

forming a first combination wafer having a support layer and a layer of solid

diamond on the support layer;

forming a second combination wafer by implanting ions into a surface of a

monocrystalline semiconductor material;

forming a third combination wafer by attaching the first combination wafer to

the second combination wafer;

shearing a portion of the monocrystalline wafer not implanted with the ions

from a portion of the monocrystalline semiconductor material implanted with the

ions, the portion of the monocrystalline semiconductor material implanted with the

ions forming a layer of solid diamond and a layer of monocrystalline semiconductor

material on one another the layer of solid diamond;

manufacturing a plurality of integrated circuits on the layer of monocrystalline

semiconductor material; and

severing the layer of solid diamond between the integrated circuits.

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30. (Previously presented) The method of claim 28, further comprising:

forming a support layer with the layer of solid diamond between the support

layer and the layer of monocrystalline semiconductor material; and

severing the support layer so that respective portions thereof form part of

respective ones of the dice.

31. (Cancelled)

32. (Previously presented) A method of making a plurality of dice, comprising:

forming a layer of solid diamond on a sacrificial wafer;

forming a layer of material on the layer of solid diamond;

implanting ions into a monocrystalline semiconductor material;

bonding a side of the monocrystalline semiconductor material through which

the ions are implanted to the layer of material;

severing a portion of the monocrystalline semiconductor material from a final

portion thereof that is bonded to the layer of material;

forming an epitaxial layer of semiconductor material on the monocrystalline

semiconductor material;

forming a plurality of integrated circuits in and on the epitaxial layer, to form a

combination wafer; and

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severing the combination wafer between the integrated circuits to singulate dice of the combination wafer from one another.

33. (Previously presented) The method of claim 32, further comprising:

removing the layer of solid diamond from at least a portion of the sacrificial

wafer.

34. (Previously presented) The method of claim 33, wherein the layer of solid

diamond is removed from the sacrificial wafer before the combination wafer is

severed to singulate the dice.

35. (Previously presented) The method of claim 32, wherein the layer of solid

diamond remains on the sacrificial wafer at least until the portion of the

monocrystalline semiconductor material is severed from the final portion thereof.